

Supplementary Information

Electron Transport Study on Functionalized Armchair Graphene Nanoribbons: DFT Calculations

Eduardo Gracia-Espino^{1,2,3}, Florentino López-Urías^{3*}, Humberto Terrones⁴, and Mauricio Terrones^{5,6,7}

¹Department of Physics, Umeå University, S-90187 Umeå, Sweden.

²Department of Chemistry, Umeå University, S-90187 Umeå, Sweden.

³Advanced Materials Department, IPICYT, Camino a la Presa San José 2055, Col. Lomas 4a sección, San Luis Potosí S.L.P., 78216, México.

⁴Department of Physics, Applied Physics and Astronomy, Rensselaer Polytechnic Institute, Troy 12180, USA.

⁵Department of Physics and Center for 2-Dimensional and Layered Materials, The Pennsylvania State University, University Park, PA 16802, USA.

⁶Department of Chemistry, Department of Materials Science and Engineering and Materials Research Institute, The Pennsylvania State University, 104 Davey Lab., University Park, PA 16802-6300, USA.

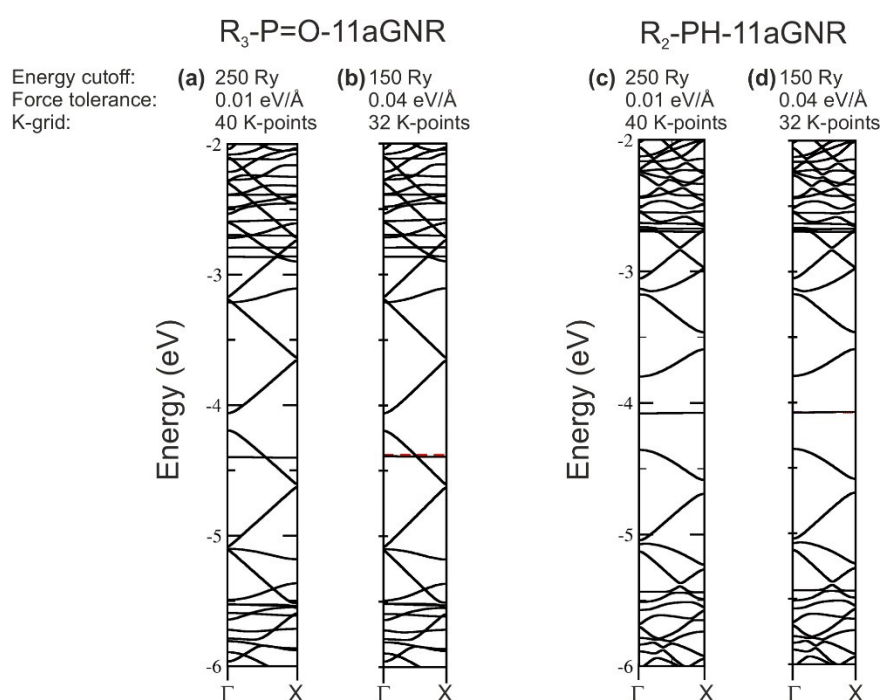


Figure S1: Band structure of (a-b) inside R_3 -P=O-11aGNR and (c-d) edge R_2 -PH-11aGNR with different computation parameters.

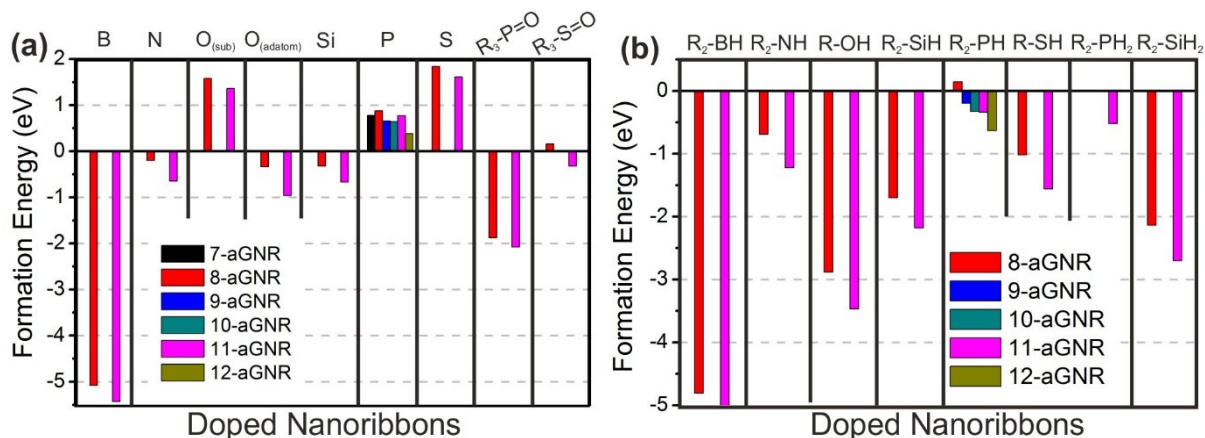


Figure S2: Formation energy of 42 armchair nanoribbons doped at the (a) inside and (b) edge. Note negative values indicate energetically favourable structures.

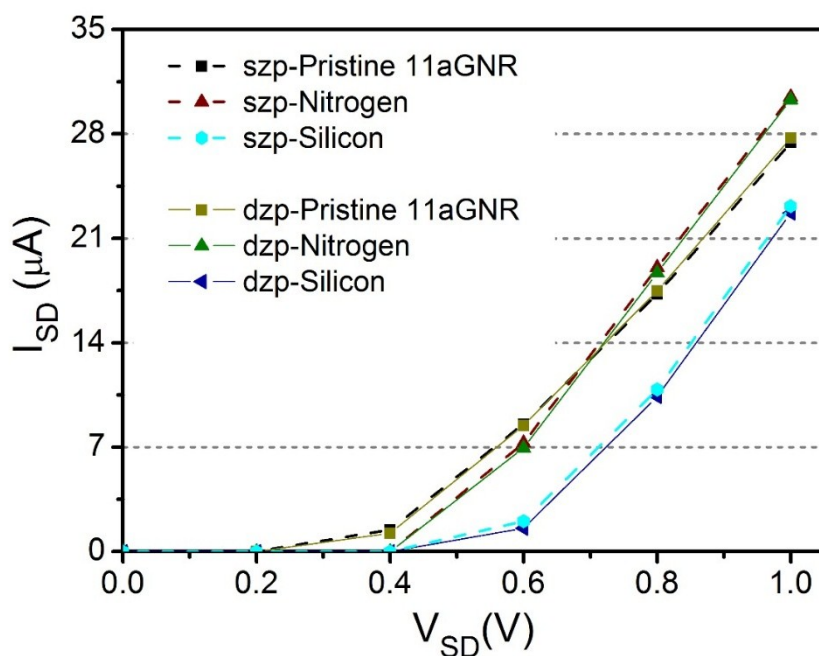


Figure S3: Current-Voltage (I - V) characteristics of undoped-, N- and Si-doped 11-aGNRs comparing the effect of using single ζ -plus-polarization basis (SZP) and double ζ -plus-polarization basis (DZP).

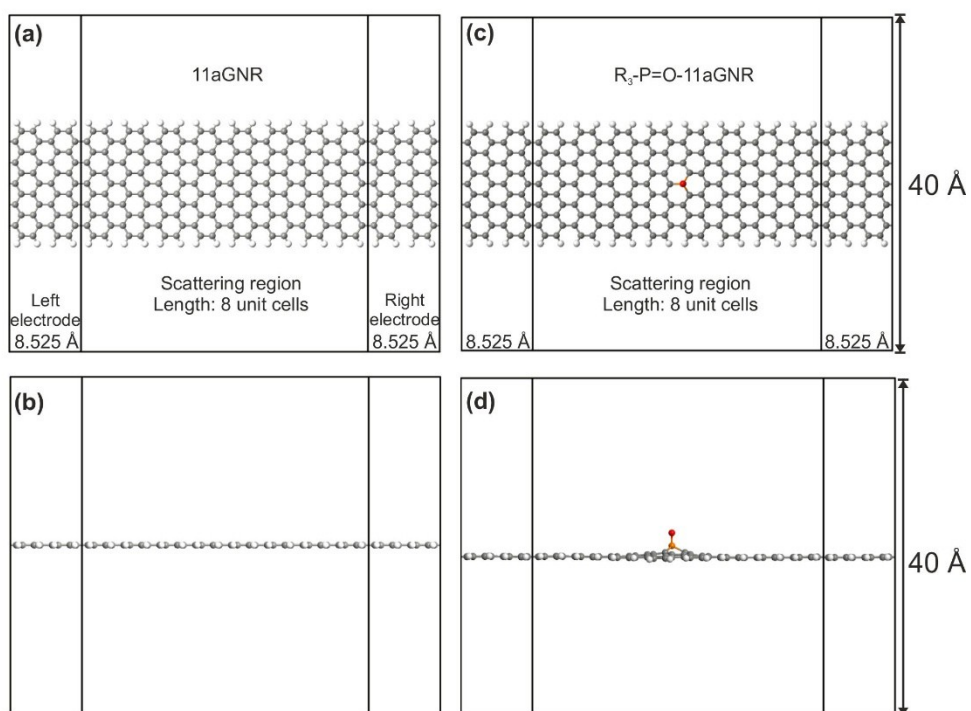


Figure S4: Devices used to determine the I-V characteristics. **(a-b)** Top and side view of the pristine 11-aGNR. **(c-d)** Top and side view of the $R_3\text{-P=O}$ -11aGNR. Other systems has a similar configuration.

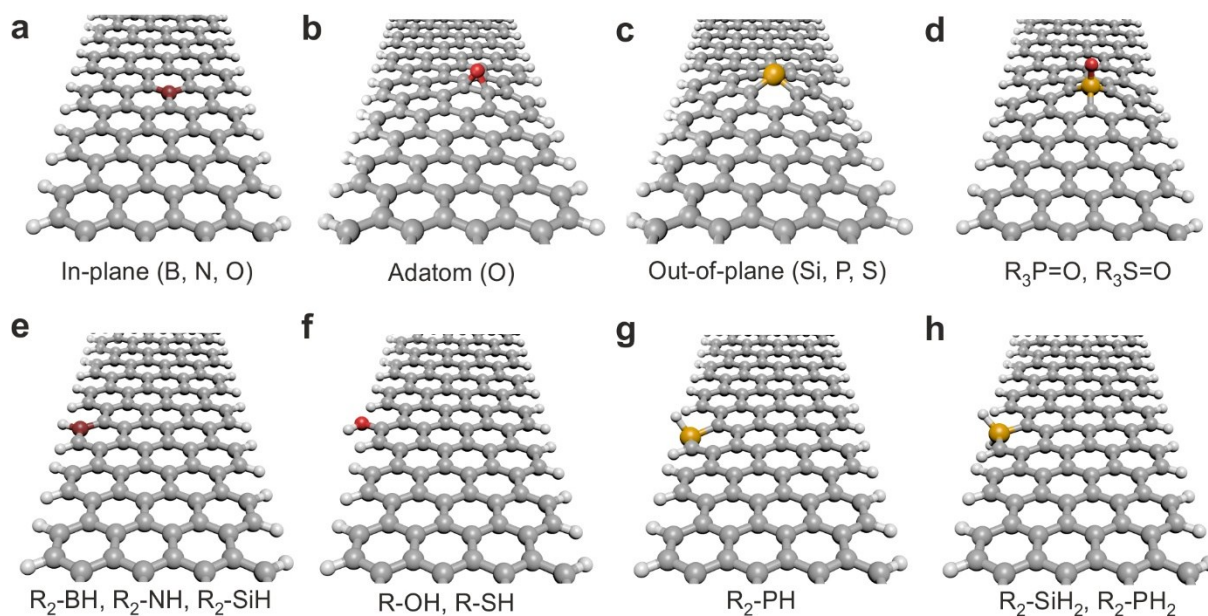


Figure S5: **(a-d)** Inside-doped and **(e-h)** edge-doped 8-aGNRs.

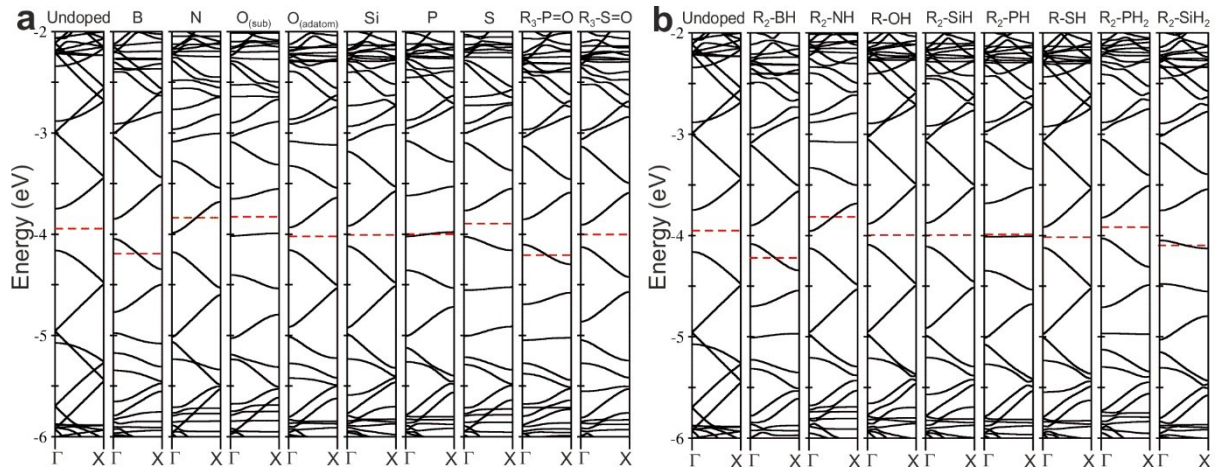


Figure S6: Band structure plots of 8-aGNRs. **(a)** Inside-doped, and **(b)** edge-doped systems. The Fermi level is indicated with a red dashed line.

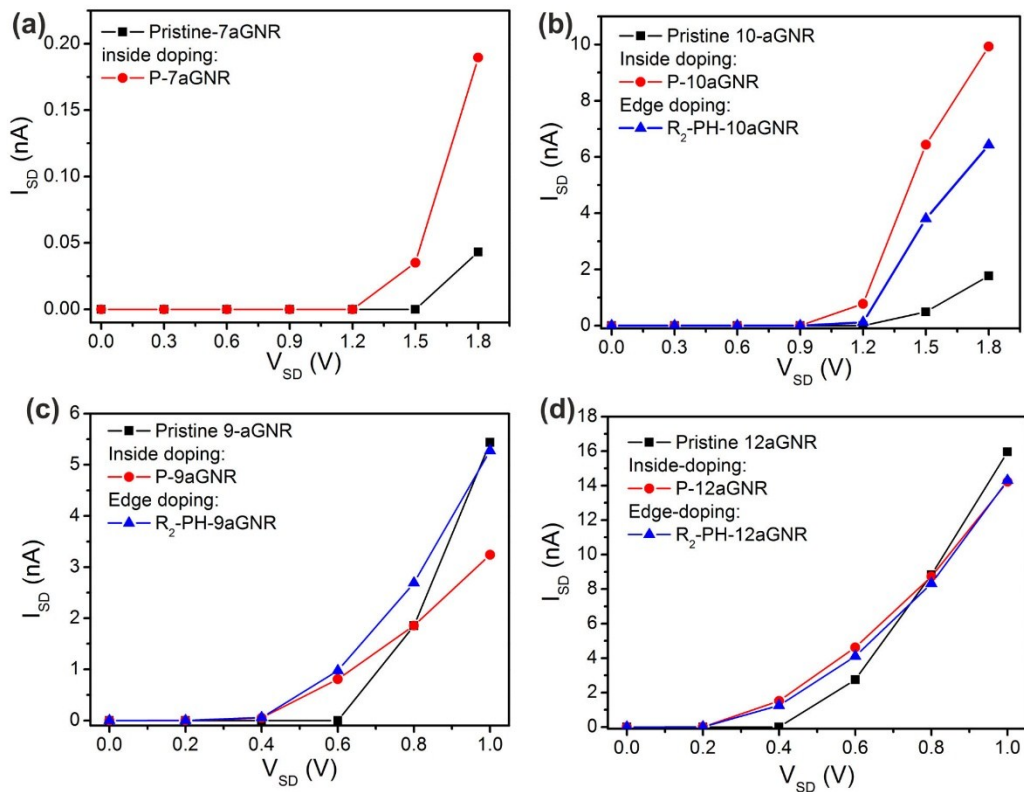


Figure S7: I-V curves of **(a)** 7- and **(b)** 10-aGNRs (3p family). **(c)** 9- and **(d)** 12aGNR (3p+1 family) with a phosphorous-inside (P-) doping and the corresponding edge case (R_2 -PH-).

Table S1: Lattice expansion and electronic band gap (E_g) of doped and undoped 11-aGNRs.

Inside-doped 11-aGNR			Edge-doped 11-aGNR		
Dopant	Lattice expansion (%)	E_g (eV)	Dopant	Lattice expansion (%)	E_g (eV)
Pristine	_**	0.331	Pristine	_**	0.331
Boron	1.68	<i>p</i> -doped	R ₂ -BH	1.60	<i>p</i> -doped
Nitrogen	1.54	<i>n</i> -doped	R ₂ -NH	1.56	<i>n</i> -doped
Oxygen (Sub)	1.54	*	R-OH	1.50	0.150
Oxygen (Adatom)	1.54	0.159			
Silicon	1.74	0.158	R ₂ -SiH	1.70	0.169
Phosphorous	1.66	*	R ₂ -PH	1.68	*
Sulfur	1.66	0.150	R-SH	1.55	0.150
R ₃ -P=O	1.66	*	R ₂ -PH ₂	1.68	0.152
R ₃ -S=O	1.66	0.161	R ₂ -SiH ₂	1.70	*

*Flat bands at the Fermi level

** Initial lattice parameter 34.10064 Å

Table S2: Lattice expansion and electronic band gap (E_g) of doped and undoped 8-aGNRs.

Center-doped 8-aGNR			Edge-doped 8-aGNR		
Dopant	Lattice expansion (%)	E_g (eV)	Dopant	Lattice expansion (%)	E_g (eV)
Pristine	_**	0.413	Pristine	_**	0.413
Boron	1.92	<i>p</i> -doped	R ₂ -BH	1.86	<i>p</i> -doped
Nitrogen	1.73	<i>n</i> -doped	R ₂ -NH	1.74	<i>n</i> -doped
Oxygen (sub)	1.77	0.368	R-OH	1.80	0.206
Oxygen (Adatom)	1.78	0.221			
Silicon	2.02	0.202	R ₂ -SiH	1.95	0.222
Phosphorous	1.93	*	R ₂ -PH	1.92	*
Sulfur	1.86	0.219	R-SH	1.78	0.202
R ₃ -P=O	1.95	-	R ₂ -PH ₂	1.95	0.204
R ₃ -S=O	1.86	0.218	R ₂ -SiH ₂	1.92	*

*Flat bands at the Fermi level

**Initial lattice parameter 34.10064 Å

Table S3: Magnetic moment on system with half-filled bands.

Doped 11-aGNR	Magnetic moment (μ_B)
O _(Sub)	0.3
P	1.0
R ₃ -P=O	0.1
Si	0.0
R ₂ -PH	1.0